

Atty Docket: Belersdorf 756-KGB/BSL

IN THE CLAIMS

Cancel claim 2.

Amend claims 1, 6, 8, 9 and 10 as follows:

- A¹
1. (Amended) Method of protecting skin from exposure to light, said method comprising the topical administration of a cosmetic or dermatological O/W formulation comprising water-soluble or water-dispersible polyurethanes having improved water resistance and further comprising at least one UV filter substance, the method further comprising the steps of:

(a) topically applying to said skin a cosmetic or dermatological formulation comprising film-forming water dispersible polyurethane composition, wherein, the polyurethane composition comprises, at least one component formed by polyaddition of (i) at least one diisocyanate and (ii) at least one diol containing acid or salt groups, with (iii) a di-hydric or poly-hydric compound selected from the group consisting of diols, aminoalcohols, diamines, polyesterols, polyetherols; and

at least one UV filtering compound;

(b) applying said composition to said skin to form a moisture resistant layer.

- A²
6. (Amended) The method of claim 1, wherein the UV filter substance is water soluble.

- A³
8. (Amended) The method of claim 1, wherein the cosmetic or dermatological preparations comprise one or more water-soluble UV-A filter substances.

9. (Amended) The method as claimed in claim 1, further comprising least one broadband filter selected from the group consisting of bis-resorcinyltriazines and derivatives thereof.

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10. (Amended) The method of claim 1, further comprising at least one broadband UV filter, wherein said filter is a benzotriazole or derivative thereof.

Add new claims 11-15.

A^{4P}
11. (New) Method of protecting skin from exposure to light, said method comprising the topical administration of a cosmetic or dermatological O/W formulation comprising water-soluble or water-dispersible cationic polyurethanes having improved water resistance and further comprising at least one UV filter substance, the method further comprising the steps of:

(a) topically applying to said skin a cosmetic or dermatological formulation comprising film-forming water dispersible polyurethane composition,

wherein, the polyurethane composition comprises,
at least one component formed by polyaddition of
(I) at least one diisocyanate that was optionally pre-reacted
with one or more compounds that contain two or more active
hydrogen atoms per molecule selected from the group
consisting of, diols, aminoalcohols, diamines, polyesterols,
polyetherols,
and

(II) at least one compound selected from the group
consisting of, diols, aminoalcohols, primary or secondary
diamines, or primary or secondary triamines having one or
more tertiary, quaternary or protonated tertiary nitrogen
atoms, and

at least one UV filtering compound;

(b) applying said composition to said skin to form a moisture
resistant layer.

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12. (New) The method of claim 8 wherein the one or more water-soluble UV-A filter substances is selected from the group consisting of phenylene-1,4-bis(2-benzimidazol-3,3'-5,5'-tetrasulfonic acid and/or 1,4-di(2-oxo-10-sulfo-3-bornylidenemethyl)benzene and/or salts thereof.

13. (New) The method of claim 12, wherein the salts of the one or more UV-A substances are selected from the group consisting of the corresponding sodium, potassium, triethanolammonium salts and phenylene-1,4-bis(2-benzimidazol-3,3'-5,5'-tetrasulfonic acid bis-sodium salt.

14. (New) The method as claimed in claim 10, wherein at least one broadband filter is selected from the group consisting of 2,2'-methylenebis(6-(2H-benzotriazol-2-yl)-4-(1,1,3,3-tetramethylbutyl)phenol) and/or 2-(2H-benzotriazol-2-yl)-4-methyl-6-[2-methyl-3-[1,3,3,3-tetramethyl-1-[(trimethylsilyl)oxy]disiloxanyl]propyl]phenol.

15. (New) The method as claimed in claim 9, wherein the broadband filter is 2,4-bis[[4-(2-ethylhexyloxy)-2-hydroxy]phenyl]-6-(4-methoxyphenyl)-1,3,5-triazine.

CONDITIONAL PETITION FOR EXTENSION OF TIME

If any extension of time for this response is required, Applicants request that this be considered a petition therefore. Please charge the required fee to Deposit Account No. 14-1263.

ADDITIONAL FEES

Please charge any further insufficiency of fees, or credit any excess to Deposit Account No. 14-1263.